



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Inventive Application of:

Hatakeyama et al.

Group Art Unit: 1752

Serial No.: 09/994,808

Examiner: LEE, Sin J.

Filed: November 28, 2001

For: AMINE COMPOUNDS, RESIST COMPOSITIONS AND PATTERNING PROCESS

SUPPLEMENTAL REPLY

Mail Stop Non Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

RECEIVED

DEC 18 2003

TC 1700

SIR:

Further to the Reply filed on December 10, 2003, please amend the claims as follows.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 12 of this paper.